

INVENTOR INFORMATION

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CORRESPONDENCE INFORMATION

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APPLICATION INFORMATION

Title Line One:: LASER ANNEALING METHOD AND SEMICONDUCTOR
Title Line Two:: DEVICE FABRICATING METHOD
Total Drawing Sheets:: 23
Formal Drawings?:: Yes
Application Type:: Utility
Docket Number:: 740756-2409
Secrecy Order in Parent Appl.?:: No

REPRESENTATIVE INFORMATION

Representative Customer Number:: 22204
Registration Number One:: 38285
Registration Number Two:: 35483
Registration Number Three:: 45285
Registration Number Four:: 27997
Registration Number Five:: 26477

PRIOR FOREIGN APPLICATIONS

Foreign Application One:: 2000-399462
Filing Date:: 12-27-2000
Country:: Japan
Priority Claimed:: Yes

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